

Day : Tuesday  
Date: 7/17/2007

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**PALM INTRANET****Inventor Name Search Result**

Your Search was:

Last Name = IMAI

First Name = GENJI

Application#	Patent#	Status	Date Filed	Title	Inventor Name
<a href="#"><u>07831572</u></a>	Not Issued	161	02/04/1992	FILM FORMING PROCESS	IMAI, GENJI
<a href="#"><u>07931328</u></a>	Not Issued	161	08/18/1992	FILM RESIST FOR DIRECT WRITING AND ETCHING PROCESS USING SAID FILM RESIST	IMAI, GENJI
<a href="#"><u>08227346</u></a>	5496678	150	04/14/1994	PHOTOSENSITIVE COMPOSITIONS CONTAINING A POLYMER WITH CARBOXYL AND HYDROXPHENYL GROUPS, A COMPOUND WITH MULTIPLE ETHYLENIC UNSATURATION AND A PHOTO-ACID GENERATOR	IMAI, GENJI
<a href="#"><u>08233443</u></a>	5527656	150	04/26/1994	POSITIVE TYPE ELECTRODEPOSITION PHOTORESIST COMPOSITIONS	IMAI, GENJI
<a href="#"><u>08382155</u></a>	5576148	150	02/01/1995	PROCESS FOR PRODUCTION OF PRINTED CIRCUIT BOARD	IMAI, GENJI
<a href="#"><u>08553978</u></a>	5650259	150	11/06/1995	PHOTOSENITIVE COMPOSITIONS AND LIQUID DEVELOPMENT	IMAI, GENJI
<a href="#"><u>08610237</u></a>	5702872	250	03/04/1996	PROCESS FOR RESIST PATTERN FORMATION USING POSITIVE ELECTRODEPOSITION PHOTORESIST COMPOSITIONS	IMAI, GENJI
<a href="#"><u>08925675</u></a>	5939148	150	09/09/1997	VISIBLE LASER-CURABLE COMPOSITION	IMAI, GENJI
<a href="#"><u>08936840</u></a>	6054251	150	09/25/1997	PHOTOPOLYMERIZABLE COMPOSITION	IMAI, GENJI
<a href="#"><u>09131418</u></a>	6106999	150	08/10/1998	PHOTOSENSITIZER, VISIBLE LIGHT CURABLE RESIN COMPOSITION USING THE	IMAI, GENJI

				SAME, AND USE OF THE COMPOSITION	
<u>09145974</u>	6124077	150	09/03/1998	VISIBLE LIGHT-SENSITIVE COMPOSITIONS AND PATTERN FORMATION PROCESS	IMAI, GENJI
<u>09154047</u>	6140025	150	09/16/1998	NEGATIVE TYPE PHOTOSENSITIVE RESIN COMPOSITION AND METHOD FOR FORMING RESIST PATTERN	IMAI, GENJI
<u>09167564</u>	6187509	150	10/07/1998	POSITIVE TYPE ELECTRODEPOSITION PHOTORESIST COMPOSITIONS AND PATTERN FORMATION PROCESS	IMAI, GENJI
<u>09193688</u>	Not Issued	161	11/18/1998	POSITIVE TYPE PHOTOSENSITIVE RESIN COMPOSITION AND METHOD FOR FORMING RESIST PATTERN	IMAI, GENJI
<u>09245028</u>	6093518	150	02/05/1999	VISIBLE LASER-CURABLE COMPOSITION	IMAI, GENJI
<u>09418368</u>	6630285	150	10/14/1999	POSITIVE SENSITIVE RESIN COMPOSITION AND A PROCESS FOR FORMING A RESIST PATTERN THEREWITH	IMAI, GENJI
<u>09442741</u>	Not Issued	161	11/18/1999	METHOD FOR FORMING RESIST LAYER AND PROCESS FOR PRODUCING PRINTED CIRCUIT BOARD	IMAI, GENJI
<u>09573387</u>	6670100	150	05/18/2000	POSITIVE TYPE ACTINIC RAY-CURABLE DRY FILM AND PATTERN-FORMING METHOD BY USE OF THE SAME	IMAI, GENJI
<u>09582557</u>	6664029	150	08/30/2000	METHOD OF FORMING PATTERN	IMAI, GENJI
<u>09582846</u>	6331376	150	07/05/2000	ORGANIC-SOLVENT-BASED PHOTOCURABLE RESIST COMPOSITION AND RESIST PATTERN-FORMING METHOD	IMAI, GENJI
<u>09630191</u>	6555286	150	08/01/2000	POSITIVE TYPE ACTINIC RAY-SENSITIVE DRY FILM AND PATTERN-FORMING METHOD BY USE OF THE SAME	IMAI, GENJI
<u>09631428</u>	Not Issued	161	08/03/2000	Laminate for pattern formation	IMAI, GENJI

<u>09673316</u>	6344307	250	10/13/2000	Photosensitive resin composition	IMAI, GENJI
<u>09708407</u>	Not Issued	161	11/09/2000	Laminate for pattern formation	IMAI, GENJI
<u>09708408</u>	Not Issued	161	11/09/2000	Laminate for pattern formation	IMAI, GENJI
<u>09831892</u>	6660457	150	05/23/2001	METHOD OF FORMING CONDUCTIVE PATTERN	IMAI, GENJI
<u>09976278</u>	6864035	150	10/15/2001	POSITIVE PHOTOSENSITIVE RESIN COMPOSITION, POSITIVE PHOTOSENSITIVE DRY FILM AND METHOD OF FORMING PATTERN	IMAI, GENJI
<u>09976279</u>	6913867	150	10/15/2001	NEGATIVE PHOTOSENSITIVE RESIN COMPOSITION, NEGATIVE PHOTOSENSITIVE DRY FILM AND METHOD OF FORMING PATTERN	IMAI, GENJI
<u>09988252</u>	Not Issued	161	11/19/2001	Method of forming conductive pattern	IMAI, GENJI
<u>09996085</u>	6699646	150	09/13/2001	POSITIVE TYPE PHOTOSENSITIVE RESIN COMPOSITION AND METHOD FOR FORMING RESIST PATTERN	IMAI, GENJI
<u>10126512</u>	Not Issued	161	04/22/2002	Negative actinic ray-sensitive paste and pattern-forming method by use of the same	IMAI, GENJI
<u>10283306</u>	6884570	150	10/30/2002	POSITIVE TYPE ACTINIC RAY-CURABLE DRY FILM AND PATTERN-FORMING METHOD BY USE OF THE SAME	IMAI, GENJI
<u>10488075</u>	7081486	150	07/28/2004	METHOD OF PRODUCING POLYMER	IMAI, GENJI
<u>10488469</u>	7078158	150	03/04/2004	COMPOSITION FOR ACTIVATION ENERGY RAYS AND METHOD OF FORMING PATTERN	IMAI, GENJI
<u>10491541</u>	Not Issued	161	04/02/2004	OPTICAL WAVEGUIDE SHEET MATERIAL AND FABRICATION METHOD FOR SAME	IMAI, GENJI
<u>10561269</u>	Not Issued	19	01/01/0001	Process for purification treatment of wastewater containing organic substance	IMAI, GENJI
<u>10588717</u>	Not	30	08/08/2006	Photocurable resin composition for	IMAI, GENJI

	Issued			optical waveguide formation, photocurable dry film for optical waveguide formation, and optical waveguide	
<a href="#"><u>10590737</u></a>	Not Issued	30	08/25/2006	Curable resin composition for optical waveguide, curable dry film for optical waveguide, optical waveguide and method for forming core part for optical waveguide	IMAI, GENJI
<a href="#"><u>10596826</u></a>	Not Issued	19	01/01/0001	POLYMER AND PROCESS FOR PRODUCING POLYMER	IMAI, GENJI
<a href="#"><u>10627891</u></a>	6946234	150	07/28/2003	POSITIVE SENSITIVE RESIN COMPOSITION AND A PROCESS FOR FORMING A RESIST PATTERN THEREWITH	IMAI, GENJI
<a href="#"><u>11018085</u></a>	Not Issued	71	12/20/2004	Curable resin composition for optical waveguide, curable dry film for formal optical waveguide, optical waveguide, and, method for forming optical waveguide	IMAI, GENJI
<a href="#"><u>11131981</u></a>	Not Issued	30	05/18/2005	Polymerization reaction apparatus, and method of producing polymer using this apparatus	IMAI, GENJI
<a href="#"><u>11185390</u></a>	Not Issued	71	07/20/2005	Method of fabricating optical waveguide	IMAI, GENJI
<a href="#"><u>11426257</u></a>	Not Issued	160	06/23/2006	POLYMER AND PROCESS FOR PRODUCING POLYMER	IMAI, GENJI
<a href="#"><u>11616705</u></a>	Not Issued	25	12/27/2006	ACTIVE ENERGY RAY-CURABLE RESIN COMPOSITION AND METHOD FOR FORMING RESIST PATTERN	IMAI, GENJI
<a href="#"><u>11632834</u></a>	Not Issued	19	01/01/0001	Near infrared ray activation type positive resin composition	IMAI, GENJI

Inventor Search Completed: No Records to Display.

<b>Search Another: Inventor</b>	<b>Last Name</b>	<b>First Name</b>
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